



IFW

PATENT
04020-P0005A WWW/DWA

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants	Wolfgang Dettman, <i>et al.</i>
Application No. 10/667,552	Filing Date: September 22, 2003
Title of Application:	Photomask, In Particular Alternating Phase Shift Mask, With Compensation Structure
Confirmation No. 9996	Art Unit: 1756
Examiner	Stephen Rosasco

Mail Stop Amendment
Commissioner for Patents
Post Office Box 1450
Alexandria, VA 22313-1450

Response to Official Action

In response to the Official Action of August 5, 2005, Applicant submits the following Amendment and Remarks. Applicant believes that no fee is due in connection with the filing of this Response. However, if any fee is due, please charge Deposit Account No. 19-4516.

Mailing Certificate: I hereby certify that this correspondence is today being deposited with the U.S. Postal Service as *First Class Mail* in an envelope addressed to: Commissioner for Patents and Trademarks; Post Office Box 1450; Alexandria, VA 22313-1450.

November 7, 2005


Paul Bosler